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Supporting Materials for

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Aligning Curved Stacking Bands to Simultaneously

3

Strengthen and Toughen Lamellar Materials

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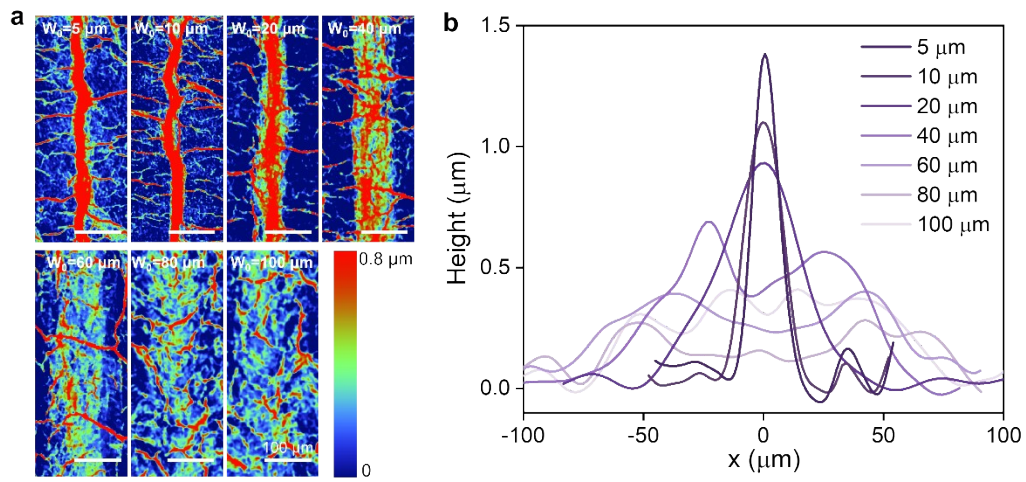
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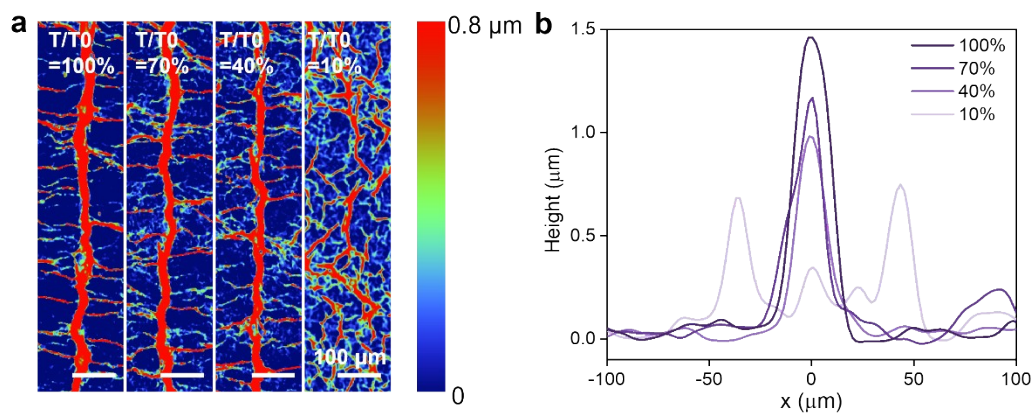
21 Fig. S1 to S18

22 Table S1

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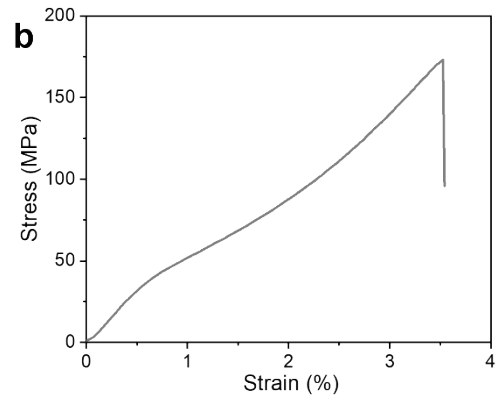
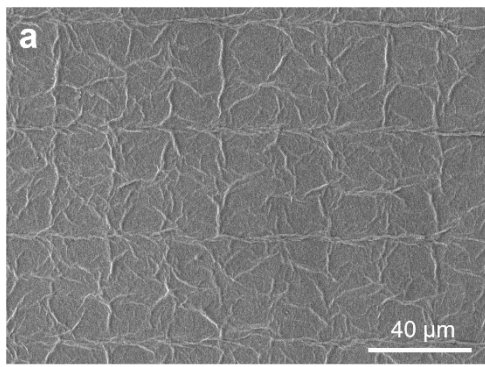
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 2 **Fig. S1** (a) WLI images of the surface morphology of CS bands constructed by probes
 3 with different diameters. (b) Typical section profiles of CS bands constructed by
 4 probes with different diameters.
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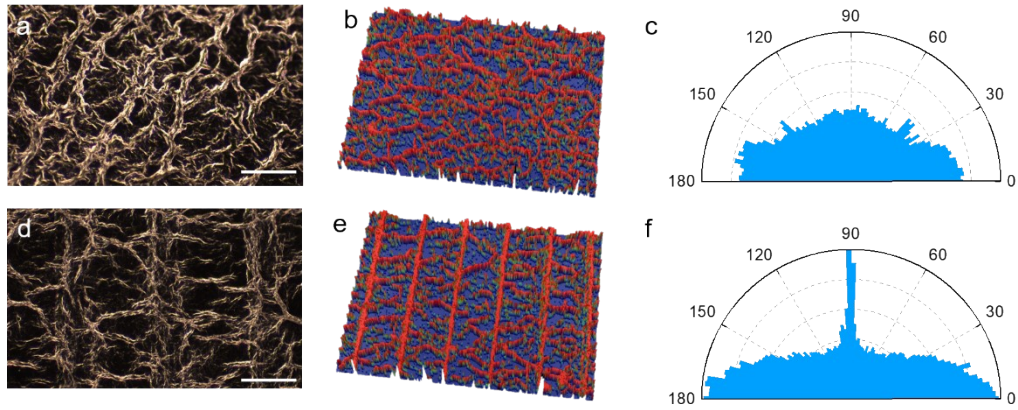
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2 **Fig. S2 (a)** WLI images of the surface morphology of CS bands constructed by probes
 3 with different relative immerse depths. **(b)** Typical section profiles of CS bands
 4 constructed by probes with different relative immerse depths.

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2 **Fig. S3 (a)** SEM images of the surface morphology of GOF films with biaxial aligned
3 CS bands. **(b)** Stress-strain curves of GOF films with biaxial aligned CS bands.
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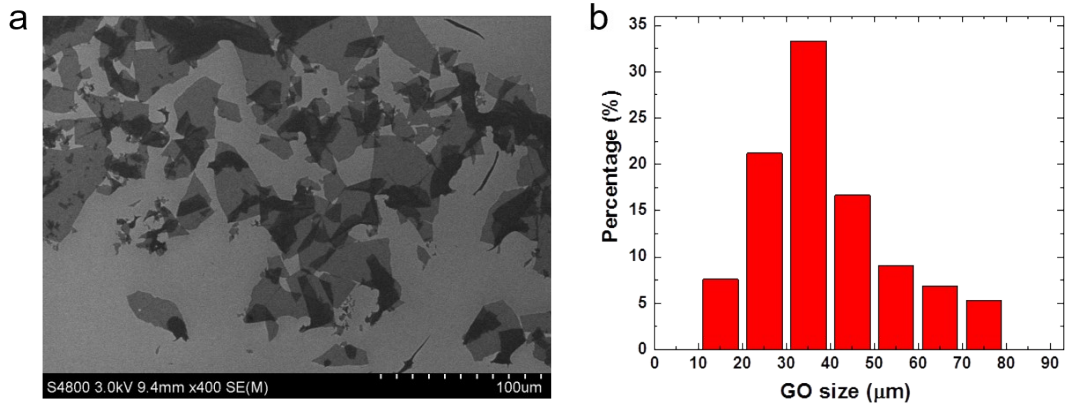
2 **Fig. S4 (a-c)** Dark field optical image (a), WLI image (b) and orientation distribution

3 (c) of the surface wrinkles for GF. **(d-f)** Dark field optical image (d), WLI image (e)

4 and orientation distribution (f) of the surface wrinkles for G200. (Scale bars: a, d 100

5 μm)

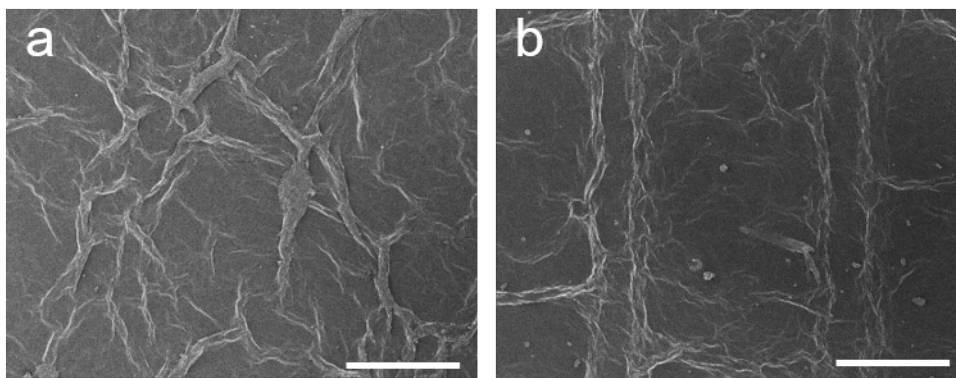
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2 **Fig. S5 (a)** SEM images of GO sheets. **(b)** Statistics of lateral size distribution of GO
3 sheets.

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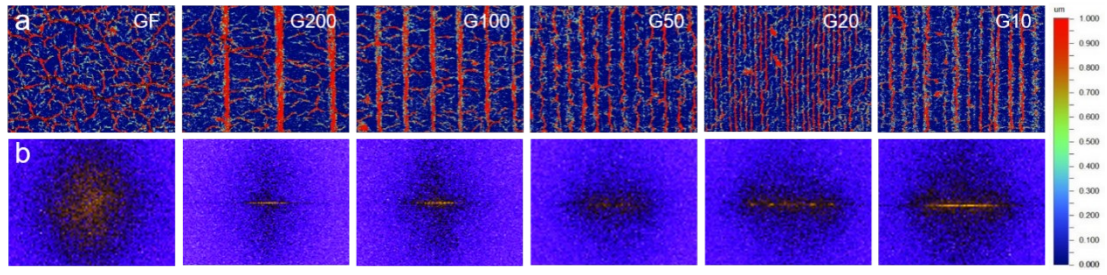


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2 **Fig. S6** SEM images of the surface wrinkles for GF (**a**) and G200 (**b**). (Scale bars: a, b

3 100 μm)

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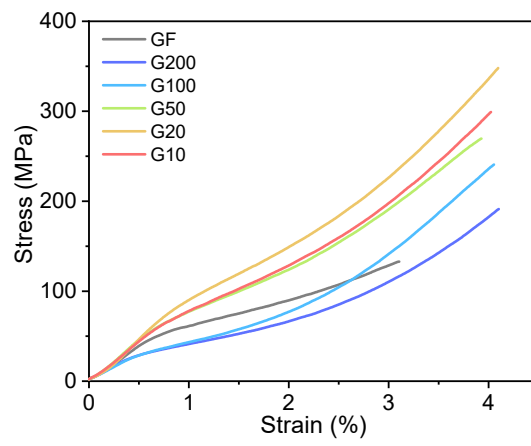


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2 **Fig. S7 (a)** WLI images of the surface wrinkle of GFs with different d . **(b)** Their

3 corresponding FFT spectra.

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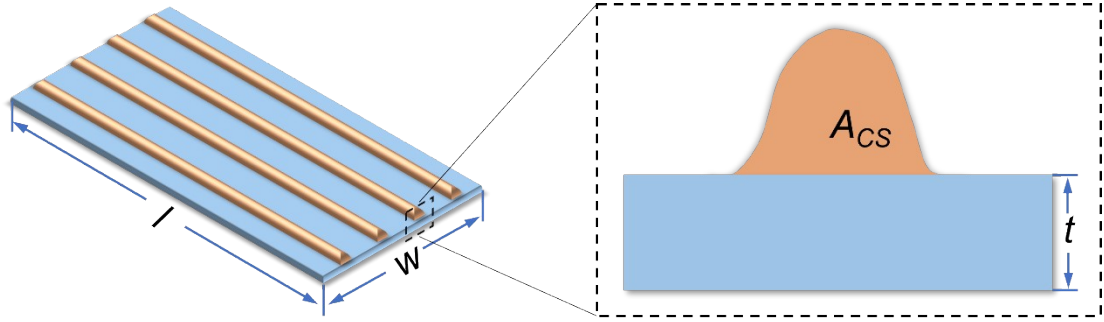
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2 **Fig. S8** Uniaxial tensile stress-strain curves for GF, G200, G100, G50, G20 and G10

3 films.

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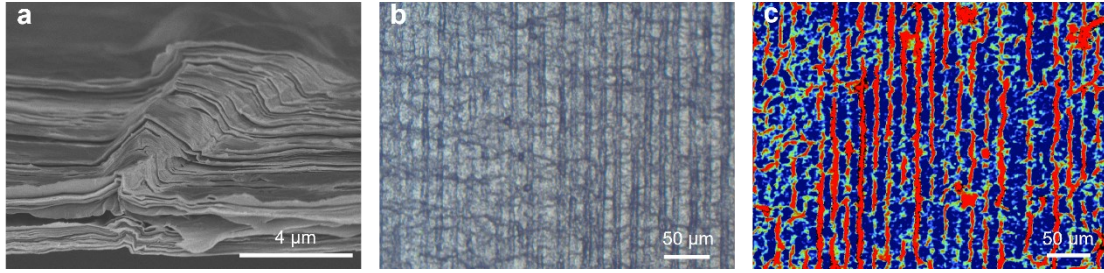


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2 **Fig. S9** Schematic diagram of the calculation process of cross-sectional areas (A) for

3 GOF with aligned ridges.

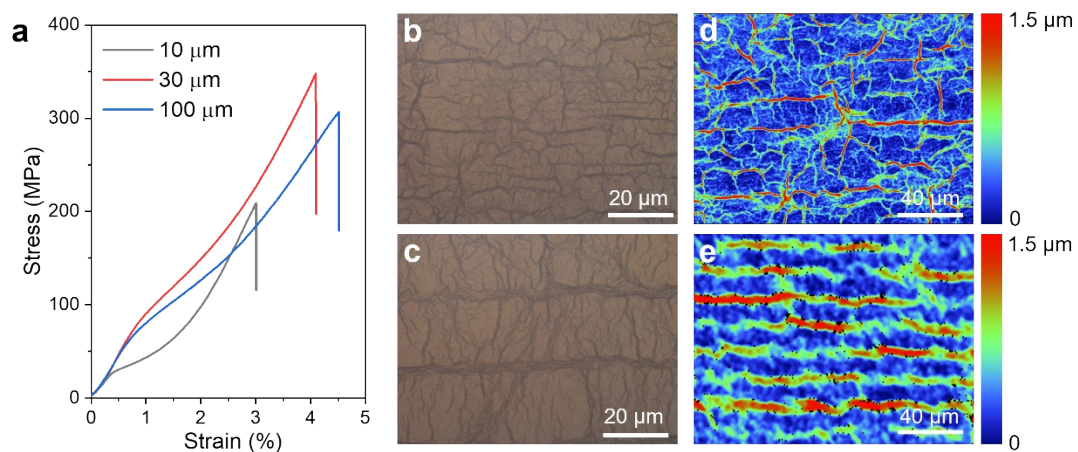
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2 **Fig. S10** (a) SEM images of the section morphology of CS bands after prolonged
3 stretching. (b, c) POM and WLI images of the surface morphology of CS bands after
4 prolonged stretching.

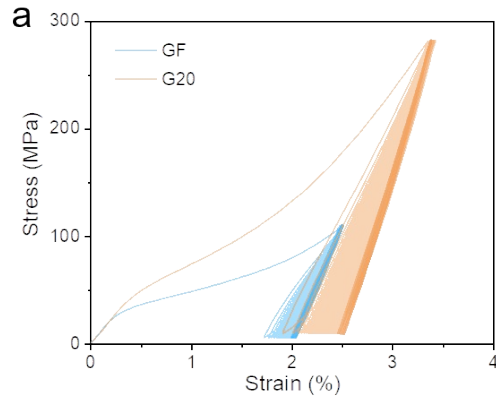
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2 **Fig. S11 (a)** Stress-strain curves of G20 films made of GO sheets with different lateral
 3 sizes. **(b, c)** POM images of the surface morphology of G20 films made of GO sheets
 4 with lateral sizes of (b) 10 μm and (c) 100 μm. **(d, e)** WLI images of the surface
 5 morphology of G20 films made of GO sheets with lateral sizes of (d) 10 μm and (e)
 6 100 μm.

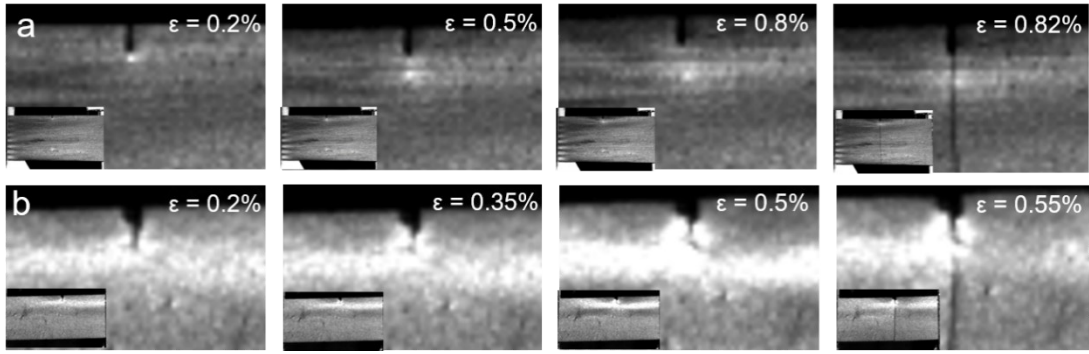
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2 **Fig. S12** Tensile stress-strain curves of GF and G20 films during 1000 tensile loading-
3 unloading cycles.

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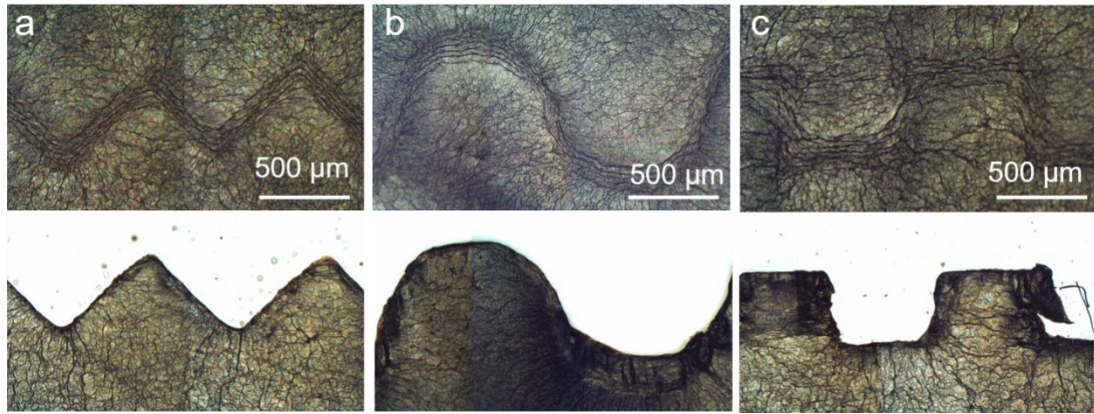


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2 **Fig. S13** Images taken by high-speed camera to track the fracture process of G20 (a)

3 and GF (b) films.

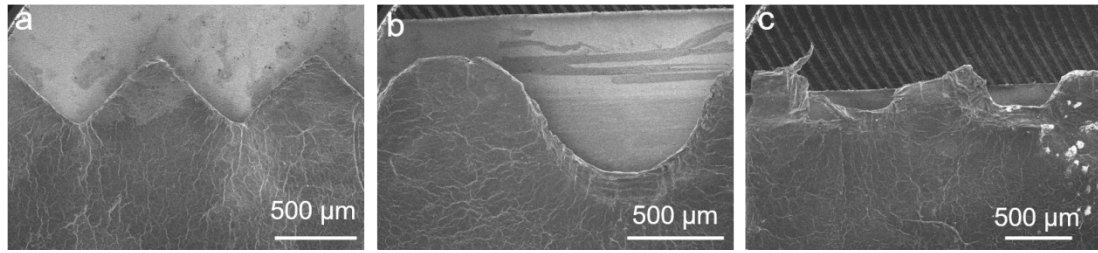
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2 **Fig. S14** Optical images of GFs with CS bands aligned in (a) jagged, (b) wavy, and (c)
3 step-like manner and their corresponding fracture surface.

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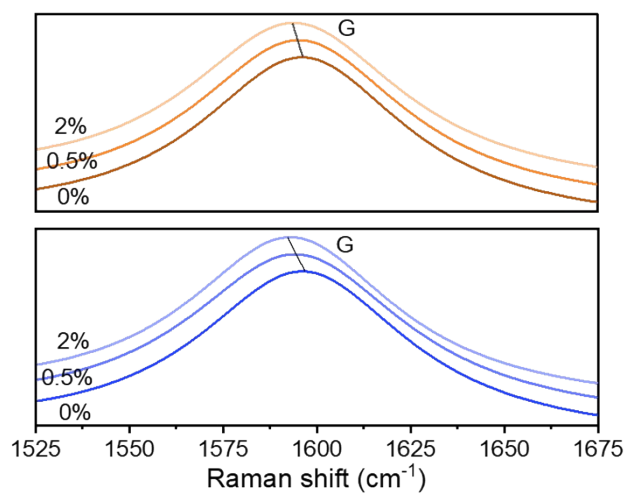


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2 **Fig. S15** SEM images of fracture surface of GFs with CS bands aligned in (a) jagged,

3 (b) wavy, and (c) step-like manner.

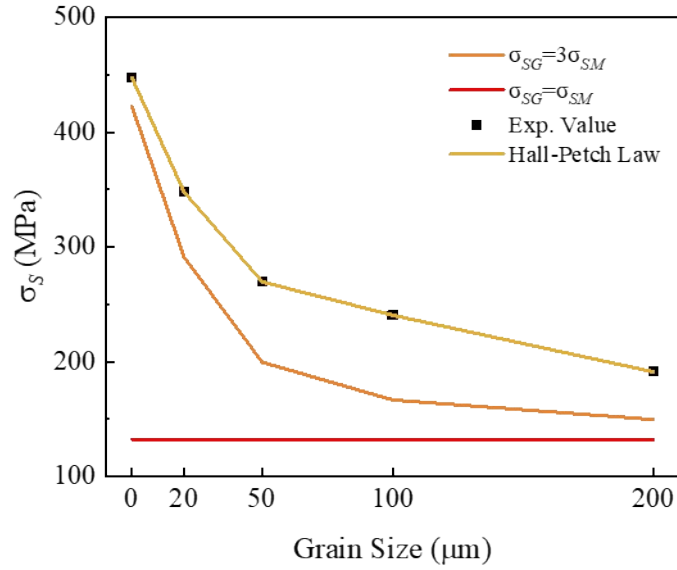
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3 **Fig. S16** The Raman shift of G peak in CS bands (top, orange) and plain area (bottom,
4 blue) for G20 films under different tensile strains.

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2 **Fig. S17** Grain size effect of LMs and CS bands enhancement effect. From the

3 perspective of composite, the mixture strength is expressed: $\bar{\sigma}_S = \sigma_{SG}f_G + \sigma_{SM}f_M$,

4 where f_G is the CS bands volume fraction, f_M is the membrane volume fraction,

5 σ_{SG} is the fracture strength of the CS bands, and σ_{SM} is the fracture strength of the

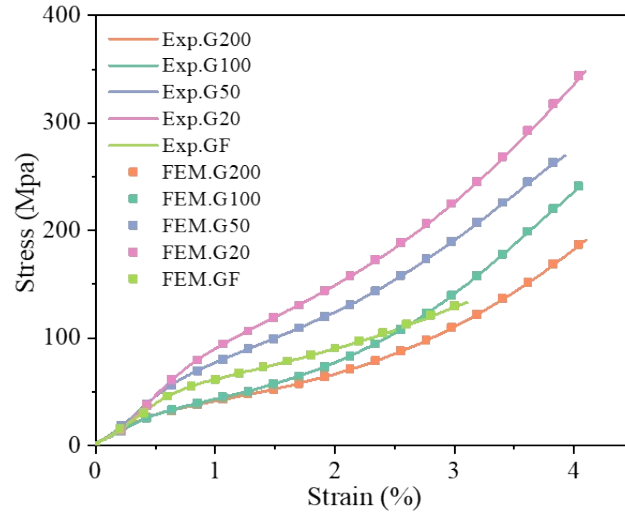
6 membrane. Even we assume the strength of CS bands is 3 times of the membrane

7 strength (we think the ridge strength is only comparable to the membrane strength due

8 to the similar constituent and structure), the predicted fracture strength is still much

9 smaller than the experiments.

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2 **Fig. S18** Comparison of FEM results with experimental stress-strain curves for

3 different GFs.

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1 **Table S1** The mechanical property data of our ridged GFs and other GO based films.

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Sample	Strength (MPa)	Toughness (MJ m ⁻³)	Reference
Nacre	200	2.6	<i>Nat. Mater.</i> 2015 , 14, 23
GO-PVA	80.2	0.1	<i>Adv. Funct. Mater.</i> 2010 , 20, 3322
GO-PMMA	148.3	2.35	<i>Adv. Funct. Mater.</i> 2010 , 20, 3322
GO-Al ₂ O ₃ -PVA	143	9.2	ACS Appl. Mater. Interfaces 2015, 7, 9281
GO-SA	240	1.3	<i>Nano Res.</i> 2016 , 9, 735
GO-Ca ²⁺	125.8	0.31	<i>ACS Nano</i> , 2008 , 2, 572
GO-Mg ²⁺	80.6	0.13	<i>ACS Nano</i> , 2008 , 2, 572
GO-Al ³⁺	100.5	0.23	<i>Nat. Chem.</i> 2015 , 7, 166
GO-Zn ²⁺	142.2	0.32	<i>Chem. Commun.</i> 2015 , 51, 2671
GO-GA	101	0.3	<i>ACS Nano</i> , 2011 , 5, 2134
GO-borate	185	0.14	<i>Adv. Mater.</i> 2011 , 23, 3842
GO-PEI	209.9	0.23	<i>Adv. Mater.</i> 2013 , 25, 2980
GO-PCDO	129.6	3.91	<i>Angew. Chem., Int. Ed.</i> , 2013 , 52, 3750
GO-PAA	91.9	0.21	<i>J. Phys. Chem. C</i> , 2009 , 113, 15801
GO-PDA	266	4.92	<i>Adv. Funct. Mater.</i> 2017 , 27, 1605636
GO-CNC	490	3.9	<i>Adv. Mater.</i> 2016 , 28, 1501
GO-annealing	211	3.91	<i>Adv. Mater.</i> 2014 , 26, 7588
GF	133	2.35	This work
G20	348	6.64	This work

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